TSMC-01-660

10/083,99 January 28, 2003

To: Commissioner of Patents and Trademarks

Washington, D.C. 20231

Fr:

George O. Saile, Reg. No. 19,572

28 Davis Ave.

Poughkeepsie, NY 12603

Subject:

NY 12603

| Serial No. 10/083,991 | 02/26/02 | CENTER 2800 |
| C. CHANG | PLANARIZATION METHOD FOR DEEP SUB MICRON SHALLOW TRENCH ISOLATION PROCESS"

Grp. Art Unit: 2812

S. ISAAC |

RESPONSE PATENT OFFICE ACTION

Dear Sir:

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In response to the Office Action dated November 29, 2002 please consider

the following arguments:

## **CERTIFICATE OF MAILING**

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner of Patents and Trademarks, Washington, D.C. 20231 on January 29, 2003.

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